Roll No.: .....

Total No. of Questions : 5]

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## W-3255(A)

## M.Sc. (Fourth Semester) Examination, (Second Chance) June-2020 PHYSICS

Paper - 404-(A)

## **Integrated Electronics**

Time : Three Hours Maximum Marks : 85 Minimum Pass Marks : 29

Note : Attempt all questions. All questions carry equal marks.

- Q.1. a) With the help of neat diagram, discuss the Float zone crystal growing method.
  - b) Discuss in detail the liquid phase epitaxy.
- Q.2. a) Explain in detail the electron beam lithography. Write its advantages over X-ray lithography.
  - b) Write short notes on
    - i) Photo mask
    - ii) Photo resist
- Q.3. Discuss in detail the design and construction of high vacuum coating unit. Also draw a neat diagram of its setup.
- Q.4. Write notes on :
  - i) Ion implantation
  - ii) Fabrication of integrated circuit.
- Q.5. Write detail notes on :
  - i) Large and medium scale integration.
  - ii) Monolithic FET and MOSFET processing.

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